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Application No.	Applicant(s)	
10/632,230	COLOMBO ET AL.	
Examiner	Art Unit	
Andy Huynh	2818	
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<u>04/12/2004</u> .		
Examiner.		
ve been received. ve been received in Application documents have been received. E" of this communication to file NMENT of this application. mitted. Note the attached EXA ives reason(s) why the oath or lust be submitted. erson's Patent Drawing Review. er's Amendment / Comment or at 1.84(c)) should be written on the the header according to 37 CF cosit of BIOLOGICAL MATE	in No in this national stage application from the a reply complying with the requirements MINER'S AMENDMENT or NOTICE OF declaration is deficient. (PTO-948) attached in the Office action of the drawings in the front (not the back) of R 1.121(d). ERIAL must be submitted. Note the	
B) 6. ☐ Interview St. Paper No./ Payor No./ B/08), 7. ☑ Examiner's t 8. ☑ Examiner's ### David Nelms Supervisory Patent Examiner **Page	ummary (PTO-413), Mail Date Amendment/Comment Statement of Reasons for Allowance -	
	Examiner Andy Huynh pears on the cover she t with S (OR REMAINS) CLOSED in 5) or other appropriate commu RIGHTS. This application is standard to the standard shape of the sta	Application No. 10/632,230 Examiner And Huynh 2818 Pears on the cover she t with the correspondence address S (OR REMAINS) CLOSED in this application. If not included 5) or other appropriate communication will be mailed in due course. THIS RIGHTS. This application is subject to withdrawal from issue at the initiative 13 and MPEP 1308. 24/12/2004 Examiner. under 35 U.S.C. § 119(a)-(d) or (f). We been received. We been received in Application No documents have been received in this national stage application from the 2** of this communication to file a reply complying with the requirements subject to this application. Whiten T of this application to file a reply complying with the requirements subject to the attached EXAMINER'S AMENDMENT or NOTICE OF invest reason(s) why the oath or declaration is deficient. Whiten T of this application to file a reply complying with the requirements submitted. Whiten T of this application to file a reply complying with the requirements of the submitted of the attached EXAMINER'S AMENDMENT or NOTICE OF invest reason(s) why the oath or declaration is deficient. Whiten T of this application to file a reply complying with the requirements of the submitted. Whiten T of this application to file a reply complying with the requirements of the file of the requirements of the file of the requirements of the file of th

U.S. Patent and Trademark Office PTOL-37 (Rev. 1-04)

DETAILED ACTION

Election/Restrictions

In the Response to Restriction Requirement dated April 12, 2004, Applicant has elected the Group I invention, claims 1-15 without traverse, drawn to a device is acknowledged. Accordingly, claims 16-21 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 35 § 1.142(b) and MPEP § 821.03. Applicant has the right to file a divisional application covering the subject matter of the non-elected claims 16-21 of the Group II invention, drawn to a method.

Examiner's Amendment

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

This application is in condition for allowance except for the presence of claims 16-21 non-elected without traverse. Accordingly, claims 16-21 have been canceled.

Allowable Subject Matter

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Claims 1-15 are allowed.

The following is an examiner's statement of reason for allowance: The prior art of record fails to teach or suggest the limitation recited a gate structure for a transistor in a semiconductor device, the gate structure comprises a dielectric structure formed over a semiconductor body, the dielectric structure comprises a bulk portion comprising a high-k dielectric material, the high-k dielectric material of the bulk portion comprising a nitrogen concentration of about 3 atomic percent or more and a nitrogen concentration variation of about 4 percent or less, and an interface portion comprising a dielectric material between the bulk portion and the semiconductor body, the interface portion having a nitrogen concentration of about 3 atomic percent or less as claimed in independent claim 1; and a gate dielectric structure in a semiconductor device, the gate dielectric structure comprises a bulk portion comprising a high-k dielectric material, the high-k dielectric material of the bulk portion comprising a nitrogen concentration of about 3 atomic percent or more and a nitrogen concentration variation of about 4 atomic percent or less; and an interface portion comprising a dielectric material between the bulk portion and a semiconductor body, the interface portion having a nitrogen concentration of about 3 atomic percent or less as claimed in independent claim 10.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance".

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Andy Huynh whose telephone number is (571) 272-1781. The examiner can normally be reached on Monday-Friday 8:30am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9306 for regular communications and (703) 872-9306 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

AH

05/03/04

Supervisory Patent Examiner
Technology Center 2800

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